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APPLICATION NO). F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/665,219	_	09/17/2003	Whonchee Lee	nee Lee 108298705US	
25096	7590	08/04/2004		EXAMINER	
PERKINS	COIE LI	LP .	NGUYEN, DUNG V		
PATENT-S	SEA				
P.O. BOX	1247		ART UNIT	PAPER NUMBER	
SEATTLE	, WA 981	11-1247	3723		
				DATE MAILED: 08/04/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
				0,			
Office Action Summary		10/665,219	LEE ET AL.				
		Examiner	Art Unit				
	The MAIL INC DATE of this communication on	Dung V Nguyen	3723	Idroop			
Period fo	The MAILING DATE of this communication aported or Reply	opears on the cover sheet wi	in the correspondence ad	iaress			
THE - External control	MORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. ensions of time may be available under the provisions of 37 CFR 1. r SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a repoperiod for reply is specified above, the maximum statutory period ure to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailined patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply within the statutory minimum of thirty divill apply and will expire SIX (6) MON te, cause the application to become AB	eply be timely filed y (30) days will be considered timel THS from the mailing date of this c ANDONED (35 U.S.C. § 133).				
Status							
1)🛛	Responsive to communication(s) filed on 211	<u>May 2004</u> .					
2a) <u></u> ☐	This action is FINAL . 2b)⊠ Thi	is action is non-final.					
3)	3) Since this application is in condition for allowance except for formal matters, prosecution as to the						
	closed in accordance with the practice under	Ex parte Quayle, 1935 C.D	. 11, 453 O.G. 213.				
Disposit	ion of Claims						
4)⊠	Claim(s) <u>1-57</u> is/are pending in the application.						
51⊠	4a) Of the above claim(s) is/are withdrawn from consideration.						
·	Claim(s) <u>39-57</u> is/are allowed. Claim(s) <u>1,3-10,13-15,19,24-32,37 <i>and</i> 38</u> is/are rejected.						
· —	Claim(s) <u>7,3-10,13-13,19,24-32,37 and 38</u> is/are rejected. Claim(s) <u>2,11,12,16-18,20-23 and 33-36</u> is/are objected to. Claim(s) are subject to restriction and/or election requirement.						
·							
Applicat	ion Papers						
9)[The specification is objected to by the Examin	ner.					
· · ·	The drawing(s) filed on is/are: a) acc		by the Examiner.				
	Applicant may not request that any objection to the	e drawing(s) be held in abeyan	ce. See 37 CFR 1.85(a).				
	Replacement drawing sheet(s) including the correct	ction is required if the drawing(s) is objected to. See 37 C	FR 1.121(d).			
11)	The oath or declaration is objected to by the E	Examiner. Note the attached	Office Action or form P	ГО-152.			
Priority	under 35 U.S.C. § 119	,					
	Acknowledgment is made of a claim for foreig All b) Some * c) None of: 1. Certified copies of the priority document		119(a)-(d) or (f).				
	2. Certified copies of the priority documen		pplication No				
	3. Copies of the certified copies of the price	·	· · · · · · · · · · · · · · · · · · ·	Stage			
	application from the International Burea	au (PCT Rule 17.2(a)).					
* (See the attached detailed Office action for a lis	et of the certified copies not	received.				
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Attachmer		A) 🗖 takanda o	tummon/ (PTO 442)				
	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948)		Summary (PTO-413) S)/Mail Date				
3) 🛛 Infor	mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 er No(s)/Mail Date <u>3/22/04</u> .		nformal Patent Application (PT	O-152)			

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DETAILED ACTION

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Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, 3, 5-9, 15, 19 and 25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chadda et al (USPN 6,464,855). Chadda et al discloses a method for removing material from a microelectronic substrate 120 comprising disposing an electrolytic liquid between an electrically conductive material of a microelectronic substrate 120 and at least one electrode160, contacting the microelectronic substrate 120 with a polishing pad material 140, electrically coupling the conductive material of the microelectronic substrate 120 to a source of varying electrical signals 80 via the electrolytic liquid and the at least one electrode 160, applying a varying electrical signal to the conductive material, moving at least one of the polishing pad material 140 and the microelectronic substrate 120 relative to the other, removing at least a portion of the conductive material from the microelectronic substrate 120 while the electronic liquid is adjacent to the electronically conductive material, controlling a normal force between the microelectronic substrate 120 and the polishing pad material 140 to be about 0.5 psi or less, oxidizing at least a portion of the conductive material by applying the varying electrical signal to the conductive material, wherein the conductive material includes tantalum, wherein the electrolytic liquid had an organic acid or organic phosphate as a

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constituent (note Fig. 4, col. 1, lines 26-35, col. 4, line 8 to col. 5, line 19). However, Chadda et al does not discloses that the electrolytic liquid having about 80%, 50%, 10% or 1% of water. It would have been obvious to one having ordinary skill in the art at the time the invention was made to select an electrolytic liquid having about 80%, 50%, 10% or 1% of water, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable range involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

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3. Claims 1, 3, 5-7 and 24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kishii et al (USPN 5,562,529). Kishii et al discloses a method for removing material from a microelectronic substrate 53 comprising disposing an electrolytic liquid between an electrically conductive material of a microelectronic substrate 53 and at least one electrode 45a, contacting the microelectronic substrate 53 with a polishing pad material 43, electrically coupling the conductive material of the microelectronic substrate 53 to a source of varying electrical signals 31 via the electrolytic liquid and the at least one electrode 45a, applying a varying electrical signal to the conductive material, moving at least one of the polishing pad material 43 and the microelectronic substrate 53 relative to the other, removing at least a portion of the conductive material from the microelectronic substrate 53 while the electronic liquid is adjacent to the electronically conductive material, positioning the first electrode 45a and a second electrode 45b proximate to and spaced apart from the microelectronic substrate 53, disposing the electrolytic liquid in fluid communication with the microelectronic substrate 53, the first electrode 45a and the second electrode 45b,

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passing the electrical signal from the first electrode 45a through the electrolytic liquid to the microelectronic substrate 53 and from the microelectronic substrate 53 through the electrolytic liquid to the second electrode 45b (note Fig. 10 and 11, col. 8, line 20 to col. 10, line 9). However, Kishii et al does not discloses that the electrolytic liquid having about 80%, 50%, 10% or 1% of water. It would have been obvious to one having ordinary skill in the art at the time the invention was made to select an electrolytic liquid having about 80%, 50%, 10% or 1% of water, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable range involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

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4. Claims 1, 3-10,13-15, 19, 25-32 and 38 are rejected under 35 U.S.C. 103(a) as being unpatentable over Liu et al (US 2003/0178320). Liu et al discloses a method for removing material from a microelectronic substrate 208 comprising disposing an electrolytic liquid between an electrically conductive material of a microelectronic substrate 208 and at least one electrode 209, the electrically conductive material including at least on of tantalum and a tantalum compound, the electrolytic liquid including a non-aqueous polar solvent, contacting the microelectronic substrate 208 with a polishing pad material 203, electrically coupling the conductive material of the microelectronic substrate 208 to a source of varying electrical signals 224 via the electrolytic liquid and the at least one electrode 209, applying a varying electrical signal to the conductive material, moving at least one of the polishing pad material 203 and the microelectronic substrate 208 relative to the other, removing at least a portion of the conductive material from the microelectronic substrate 208 while the electronic liquid is

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adjacent to the electronically conductive material, complexing the tantalum as a metalorganic species in solution, controlling a normal force between the microelectronic substrate 120 and the polishing pad material 140 to be about 1 psi or less wherein the electrolytic liquid includes an organic solvent and a salt as constituent (note Fig. 1, paragraph [0019] to [0087]). However, Liu et al does not discloses that the electrolytic liquid having about 80%, 50%, 10% or 1% of water. It would have been obvious to one having ordinary skill in the art at the time the invention was made to select an electrolytic liquid having about 80%, 50%, 10% or 1% of water, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable range involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

5. Claim 37 is rejected under 35 U.S.C. 103(a) as being unpatentable over Liu et al (US 2003/0178320) as applied to claim 26 above, and further in view of Kishii et al (USPN 5,562,529). Liu et al discloses the claimed invention as described above, however, Liu et al does not disclose positioning the first electrode and a second electrode proximate to and spaced apart from the microelectronic substrate, disposing the electrolytic liquid in fluid communication with the microelectronic substrate, the first electrode and the second electrode, passing the electrical signal from the first electrode through the electrolytic liquid to the microelectronic substrate and from the microelectronic substrate through the electrode. Kishii et al discloses positioning the first electrode 45a and a second electrode 45b proximate to and spaced apart from the microelectronic substrate 53, disposing the electrolytic

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liquid in fluid communication with the microelectronic substrate 53, the first electrode 45a and the second electrode 45b, passing the electrical signal from the first electrode 45a through the electrolytic liquid to the microelectronic substrate 53 and from the microelectronic substrate 53 through the electrolytic liquid to the second electrode 45b (note Fig. 10 and 11, col. 8, line 20 to col. 10, line 9).. It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the method for removing material of Liu et al with the steps disclosed by Kishii et al in order to uniformly polish a whole surface of a substrate.

Allowable Subject Matter

- 6. Claims 39-57 are allowed.
- 7. Claims 2, 11, 12, 16-18 and 20-23 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

- 8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Hisamatsu et al and Easter et al are cited to show electrochemical mechanical planarization apparatus and method.
- 9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dung V Nguyen whose telephone number is 703-305-0036. The examiner can normally be reached on M-F, 6:30-3:00.

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10. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph J Hail can be reached on 703-308-2687. The fax phone number for

the organization where this application or proceeding is assigned is 703-872-9306.

11. Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

DVN August 2, 2004

> DUNG VAN NGUYEN PRIMARY EXAMINER

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